Structure investigation of ultrananocrystalline diamond/amorphous carbon composite films in vacuum by a coaxial arc plasma gun

<u>Kenji Hanada¹</u>, Tomohiro Yoshida¹, You Nakagawa¹, Ryota Ohtani², Kazushi Sumitani², Hiroyuki Setoyama², Eiichi Kobayashi², and Tsuyoshi Yoshitake¹;

- ¹ Department of Applied Science for Electronics & Materials, Kyushu University, 6-1 Kasuga, Fukuoka 816-8580, Japan
- ² Kyushu Synchrotron Light Research Center, 8-7 Yayogigaoka, Tosu, Saga 841-0005, Japan



Abstract

Ultrananocrystalline diamond (UNCD)/non-hydrogenated amorphous carbon (a-C) composite films were grown in vacuum by using a coaxial arc plasma gun. From the X-ray diffraction measurement, the UNCD crystallite size was estimated to be 1.6 nm. The size is dramatically reduced from that (2.3 nm) of UNCD/hydrogenated amorphous carbon (a-C:H) composite films grown in a hydrogen atmosphere. The sp³/(sp³ + sp²) value, which was estimated from the X-ray photoemission spectrum, was also reduced to be 36%. A reason might be the reduction in the UNCD crystallite size. From the near-edge X-ray absorption fine-structure (NEXAFS) spectrum, it was found that the $\pi^*C=C$ and $\pi^*C=C$ bonds are preferentially formed instead of the $\sigma^*C=H$ bonds in the UNCD/a-C:H films. Since the extremely small UNCD crystallites (1.6 nm) correspond to the nuclei of diamond, we believe that the UNCD crystallite formation by CAPD should be predominantly due to nucleation.





